Special Issue

Applied Deep Learning and Machine Learning in Drug Design and Discovery

Message from the Guest Editor

This Special Issue focuses on the application of deep learning and machine learning techniques in the field of drug design and discovery. It aims to explore the innovative ways in which these advanced computational approaches are being employed to accelerate drug development, optimize molecular structures, predict drug-target interactions, and enhance our understanding of complex biological systems. The articles featured in this issue will showcase cutting-edge research and developments at the intersection of artificial intelligence, chemistry, and biology, contributing to the advancement of pharmaceutical science and therapeutics. Keywords:

- drug design
- drug discovery
- artificial intelligence
- machine learning
- deep learning
- drug-target interactions
- drug-drug interactions

Guest Editor

Dr. Junghyun Kim

Department of Artificial Intelligence, Sejong University, Seoul 05006, Republic of Korea

Deadline for manuscript submissions

closed (15 March 2024)



Applied Sciences

an Open Access Journal by MDPI

Impact Factor 2.5 CiteScore 5.5



mdpi.com/si/181902

Applied Sciences
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
applisci@mdpi.com

mdpi.com/journal/

applsci





Applied Sciences

an Open Access Journal by MDPI

Impact Factor 2.5 CiteScore 5.5



About the Journal

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

Prof. Dr. Giulio Nicola Cerullo

Dipartimento di Fisica, Politecnico di Milano, Piazza L. da Vinci 32, 20133 Milano, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, CAPlus / SciFinder, and other databases.

Journal Rank:

JCR - Q2 (Engineering, Multidisciplinary) / CiteScore - Q1 (General Engineering)

